

Abstract

In order to capture an image of polysilicon, polysilicon varying in shape and/or size is inverted. An inversion device (3) includes: a first sandwiching part (31) including a first elastically deforming part (311) that elastically deforms; a second sandwiching part (32) including a second elastically deforming part (321) that elastically deforms; and an inversion mechanism (33A, 33B) that, for capturing of an image of polysilicon (S), inverts the polysilicon (S) in a sandwiched state in which the polysilicon (S) is sandwiched between the first elastically deforming part (311) and the second elastically deforming part (321).

(Figure 2)